

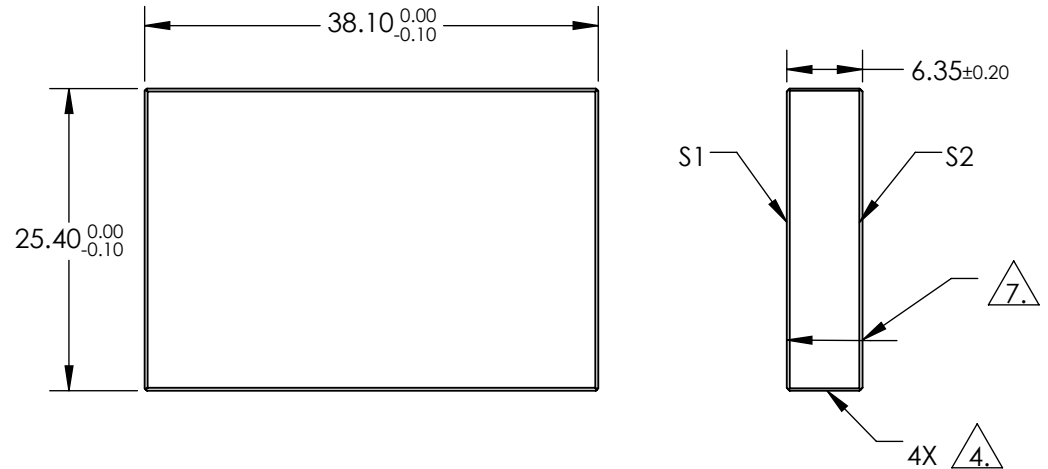
NOTES:

1. SUBSTRATE:
Fused Silica
2. SURFACE S1 TO BE PARALLEL TO SURFACE S2 TO WITHIN <3 ARCMINS
3. COATING (APPLY ACROSS COATING APERTURE)

S1: R(ABS) >99.8% @ 515nm
DAMAGE THRESHOLD,
PULSED: 10 J/cm² @ 515nm, 20ns, 20Hz
CW: 1MW/cm² @ 515nm

S2: NONE

4. FINE GROUND SURFACE
5. CLEAR APERTURE AND COATING APERTURE ARE CENTERED ON SURFACE
6. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
7. ARROW ON EDGE WITH LASER ETCH, PENCIL, OR PERMANENT INK POINTS TOWARDS SURFACE S1



**FOR INFORMATION ONLY:
DO NOT MANUFACTURE
PARTS TO THIS DRAWING**

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	10-5	COMMERCIAL POLISH
SURFACE FLATNESS	0.10 WAVE	N/A
MIN CLEAR APERTURE	21.59 x 32.39	N/A
MIN COATING APERTURE	21.59 x 32.39	N/A
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED



ALL DIMS IN

mm

EO® **Edmund Optics**®

TITLE

25.4 x 38.1mm 515nm 0-45°, Yb:YAG Laser
Line Mirror

DWG NO

39638

SHEET
1 OF 1